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(71) Applicants (for all designated States except US): **SHOWA DENKO K.K.** [JP/JP]; 13-9, Shibadaimon 1-chome, Minato-ku, Tokyo 105-8518 (JP). **KABUSHIKI KAISHA TOSHIBA** [JP/JP]; 1-1-1, Shibaura, Minato-ku, Tokyo 105-8001 (JP).

(72) Inventors; and

(75) Inventors/Applicants (for US only): **SHIMIZU, Kenji** [JP/JP]; Showa Denko HD K.K., 5-1, Yawata Kaigan dori, Ichihara-shi, Chiba 290-0067 (JP). **SAKAWAKI, Akira** [JP/JP]; Showa Denko HD K.K., 5-1, Yawata Kaigan dori, Ichihara-shi, Chiba 290-0067 (JP). **KOBAYASHI, Kazuo** [JP/JP]; Showa Denko HD K.K., 5-1, Yawata Kaigan dori, Ichihara-shi, Chiba 290-0067 (JP). **NGUYEN, Tien, Duong** [JP/JP]; Showa Denko HD K.K., 5-1, Yawata Kaigan dori, Ichihara-shi, Chiba 290-0067 (JP). **SAKAI, Hiroshi** [JP/JP]; Showa Denko HD K.K.,

5-1, Yawata Kaigan dori, Ichihara-shi, Chiba 290-0067 (JP). **HIKOSAKA, Takashi** [JP/JP]; Kabushiki Kaisha Toshiba, Ome Complex, 2-9, Suehiro-cho, Ome-shi, Tokyo 143-0025 (JP). **OIKAWA, Soichi** [JP/JP]; Kabushiki Kaisha Toshiba, Ome Complex, 2-9, Suehiro-cho, Ome-shi, Tokyo 143-0025 (JP). **MAEDA, Tomoyuki** [JP/JP]; Kabushiki Kaisha Toshiba, Ome Complex, 2-9, Suehiro-cho, Ome-shi, Tokyo 143-0025 (JP). **NAKA-MURA, Futoshi** [JP/JP]; Kabushiki Kaisha Toshiba, Ome Complex, 2-9, Suehiro-cho, Ome-shi, Tokyo 143-0025 (JP).

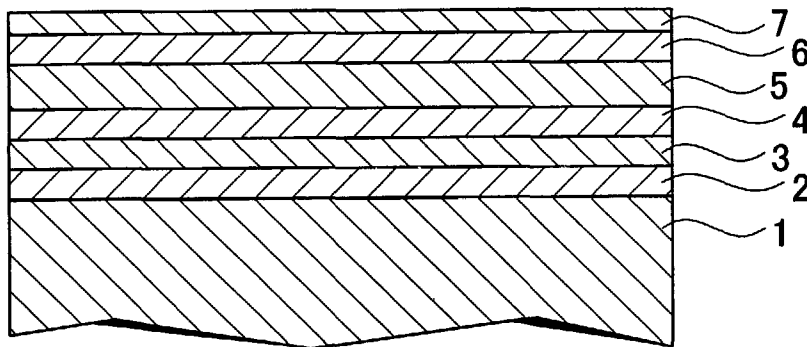
(74) Agents: **SHIGA, Masatake** et al.; 2-3-1 Yaesu, Chuo-ku, Tokyo 104-8453 (JP).

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[Continued on next page]

(54) Title: MAGNETIC RECORDING MEDIUM, METHOD OF MANUFACTURING THEREFOR, AND MAGNETIC READ/WRITE APPARATUS



(57) Abstract: A soft magnetic undercoat film, a first undercoat film, a second undercoat film, a perpendicular magnetic recording film, and a protective film are provided on a non-magnetic substrate, and the first undercoat film consists of Pt, Pd, or an alloy including at least one among these, and the second undercoat film consists of Ru or an Ru alloy.

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